

Enhancing thermoelectric performance of band structure engineered $\text{GeSe}_{1-x}\text{Te}_x$ alloys

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Supplementary material

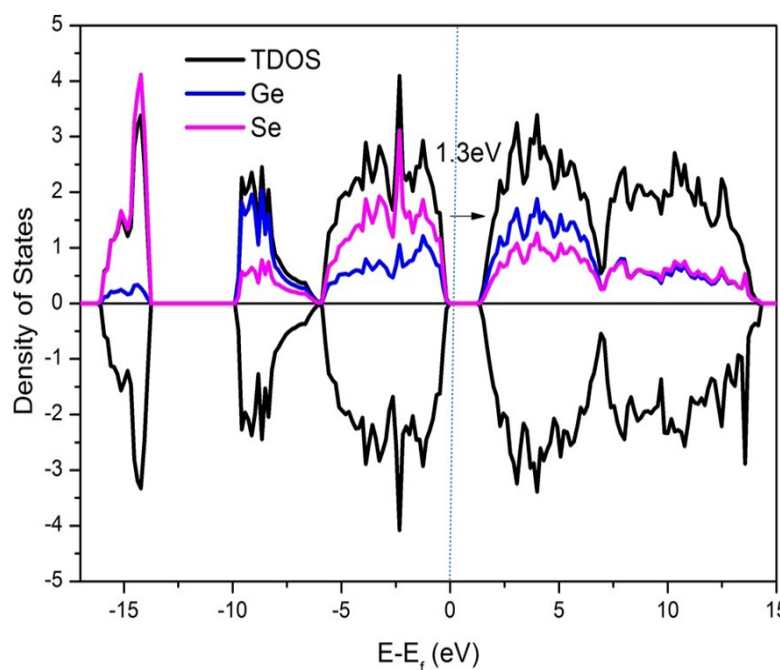


Figure S1 Total and Partial Density of states of GeSe calculated using HSE06 level of theory